Attorney's Docket No.: 12732-170001 / US6682

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Satoru Okamoto Art Unit : 1792

Serial No.: 10/689,617 Examiner: Mahmoud Dahimene

Filed : October 22, 2003 Conf. No. : 4799

Title : METHOD FOR CLEANING PLASMA ETCHING APPARATUS, METHOD

FOR PLASMA ETCHING, AND METHOD FOR MANUFACTURING

SEMICONDUCTOR DEVICE

## MAIL STOP AF

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

## NOTICE OF APPEAL

Applicant hereby appeals to the Board of Patent Appeals and Interferences from the action dated April 22, 2008, twice rejecting claims 1-95.

The fee in the amount of \$510 for the appeal fee is being paid concurrently herewith on the Electronic Filing System (EFS) by way of Deposit Account authorization. Please apply any other charges or credits to Deposit Account No. 06-1050.

Respectfully submitted,

Date:July 22, 2008

/Diana DiBerardino/

Diana DiBerardino Reg. No. 45,653

Fish & Richardson P.C. 1425 K Street, N.W.

11th Floor

Washington, DC 20005-3500 Telephone: (202) 783-5070 Facsimile: (877) 769-7945

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